

1	1. A method for forming an aperture plate, the method comprising:
2	providing a mandrel comprising a plate body having a conductive surface
3	and a plurality of non-conductive islands disposed on the conductive surface, wherein the
4	islands extend above the conductive surface and are sloped relative to the conductive
5	surface;
6	placing the mandrel within a solution containing a material that is to be
7	deposited onto the mandrel;
8	applying/electrical current to the mandrel to form an aperture plate on the
9	mandrel, wherein the apertures have an exit angle that is in the range from about 30° to
10	about 60°.
1	2. A method as in claim 1, wherein the islands have a geometry that
1	approaches a generally conical shape, and wherein the islands have a base diameter in the
2	range from about 20 microns to about 200 microns and a height in the range from about 4
4	microns to about 20 microns.
7	inferons to about 20 inferons.
1	A method as in claim 1, wherein the islands have an average slope
2	in the range from about 15° to about 30° relative to the conductive surface.
1	A method as in claim 3, further comprising forming the islands
2 -	from a photoresist material using a photolithography process.
1	5. A method as in claim 4, further comprising treating the islands
2	following the photolithography process to alter the shape of the islands.
	Control of the control of the denosited
1	6. A method as in claim 1, further comprising removing the deposited
2	aperture plate from the mandrel and forming a dome shape in the aperture plate.
1	7. A method as in claim 1, wherein the material in the solution is
2	selected from a group of materials consisting of palladium, palladium nickel, and
3	palladium alloys.
	a la
1	8. A method as in claim 1, wherein the apertures have an exit angle
2	that is in the range from about 41° to about 49°.
1	9. An aperture plate formed according to the process of claim 1.

	Subbl		
1		10.	An aperture plate comprising:
2	,	_	e body having a top surface, a bottom surface, and a plurality of
3	•	_	from the top surface to the bottom surface, wherein the apertures are
4	-		from the top surface to the bottom surface, and wherein the
5			it angle that is in the range from about 30° to about 60°, and a
6	diameter that	is in th	e range from about 1 micron to about 10 microns at the narrowest
7	portion of the	e taper.	
1		11.	An aperture plate as in claim 10, wherein the plate body is
2	constructed f	rom ma	terials selected from a group consisting of palladium, palladium
3	nickel and pa	lladium	alloys.
1		12.	An aperture plate as in claim 10, wherein the plate body includes a
2	portion that i	s dome	shaped in geometry.
1		13.	An aperture plate as in claim 10, wherein the plate body has a
2	thickness in	the rang	e from about 20 microns to about 70 microns.
1		14/	An aperture plate as in claim 10, wherein the apertures have an exit
2	angle that is	in the ra	ange from about 41° to about 49°.
_	g. 0 10	,	
1		15.	A mandred for forming an aperture plate, the mandrel comprising:
2			ndrel body having a conductive, generally flat top surface and a
3			ductive islands disposed on the conductive surface, wherein the
4	islands exten	d above	e the conductive surface and have a geometry approaching a generally
5	conical shape	€.	
1		16.	A mandrel as in claim 15, wherein the islands have a base diameter
2	in the range	from ab	out 20 microns to about 200 microns, a height in the range from
3	about 4 micr	ons to a	bout 20 microns
1		17.	A mandrel as in claim 15, wherein the islands are formed from a
2	photoresist r	naterial	using a photolithography process.
1		18.	A method as in claim 17, wherein the islands are treated following
2	the photolith	ography	y process to alter the shape of the islands.

1		19.	A method for producing a mandrel that is adapted to form an
2	aperture plate	, the me	thod comprising:
3		a) pro	viding an electroforming mandrel body;
4		b) app	olying a photoresist film to the mandrel body;
5		c) pla	cing a mask having a pattern of circular regions over the photoresist
6	film;		
7		d) dev	veloping the photoresist film to form an arrangement of non-
8	conductive isl	ands co	rresponding to the location of the holes in the pattern; and
9		e) hea	ting the mandrel body to permit the islands to melt and flow into a
10	desired shape		
1		20.	A method as in claim 19, further comprising repeating steps b)
2	through e) wh	ere the	pattern of circular regions of the mask are smaller.
	-		
1		21.	A method as in claim 20, wherein the desired shape is generally
2	conical.		
1		22.	A method as in claim 20 further comprising permitting the islands
2	to cure before	repeati	ng the steps.
1		23.	A method as in claim 20, further comprising heating the mandrel
2	body until the	islands	have an average angle of taper that is in the range from about 15° to
3	about 30°.		
1		24.	A method as in claim 19, wherein the photoresist film has a
2	thickness in t	he range	e from about 4 microns to about 15 microns.
1		25.	A method as in claim 19, wherein the mandrel body is heated to a
2	temperature i	n the ra	nge from about 50°C to about 250° C for about 30 minutes.
1		26.	A method as in claim 25, further comprising raising the
2	temperature a	it a rate	that is less than about 3°C per minute until reaching the desired
3	range.		
1		27.	A method for aerosolizing a liquid, the method comprising:

2	providing an aperture plate comprising a plate body having a top surface, a		
3	bottom surface, and a plurality of apertures that taper in a direction from the top surface		
4	to the bottom surface, wherein the apertures have an exit angle that is in the range from		
5	about 30° to about 60°, and a diameter that is in the range from about 1 micron to about		
6	10 microns at the narrowest portion of the taper;		
7	supplying a liquid to the bottom surface of the aperture plate; and		
8	vibrating the aperture plate to eject liquid droplets from the top surface.		
1	28. A method as in claim 27, wherein the droplets have a size in the		
2	range from about 2 microns to about 10 microns.		
	29. A method as in claim 27, further comprising holding the supplied		
1	29. A method as in claim 27, further comprising holding the supplied liquid to the bottom surface by surface tension forces until the liquid droplets are ejected		
2	/		
3	from the top surface.		
1	30. A method as in claim 27, wherein the aperture plate has a least		
2	about 1000 apertures which product droplets having a size in the range from about 2		
3	microns to about 10 microns, and further comprising aerosolizing a volume of liquid in		
4	the range from about 4µL to about 30µL within a time of less than about one second.		
5			
6	31. An aperture plate comprising:		
7	a plate body having a top surface, a bottom surface, and a plurality of		
8	apertures extending from the top surface to the bottom surface, wherein the apertures each		
9	include an upper portion and a lower portion, wherein the lower portion extends upwardly		
10	from the bottom surface and is generally concave in geometry, and wherein the upper		
11	portion is tapered in a direction from the top surface to the bottom surface and		
12	intersections with the lower portion.		
13			
14	32. An aperture plate as in claim 31, wherein upper portion has an angle		
15	of taper that is in the range from about 30° to about 60° at the intersection with the lower		
16	portion, and a diameter that is in the range from about 1 micron to about 10 microns at the		
17	intersection with the lower portion.		
18			

19	33. An aperture plate as in claim 32, wherein the lower portion has a
20	diamter at the lower surface that is in the range from about 20 microns to about 200
21	microns, a height in the range from about 4 microns to about 20 microns.
22	
23	34. An aperture plate as in claim 31, wherein the bottom surface is
24	adpated to receive a liquid, and wherein the plate body is vibratable to eject liquid
25	droplets from the front surface.
26	
27	35. A method for ejecting droplets of liquid, the method comprising:
28	providing an aperture plate comprising a plate body having a top surface, a bottom
29	surface, and a plurality of apertures that taper in a direction from the top surface to the
30	bottom surface, wherein the apertures have an exit angle that is in the range from about
31	30° to about 60°, and a diameter that is in the range from about 1 micron to about 10
32	microns at the narrowest portion of the taper; and
33	forcing liquid through the apertures to eject liquid droplets from the front surface.
34	Addbox